

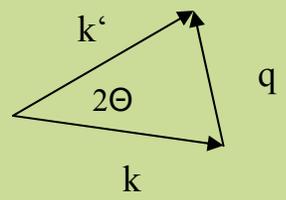
- **An absolute intensity calibration at BW4
by using a reference sample**
- **GISAXS Experiment – Au-nanoclusters on
a Si-111 surface**

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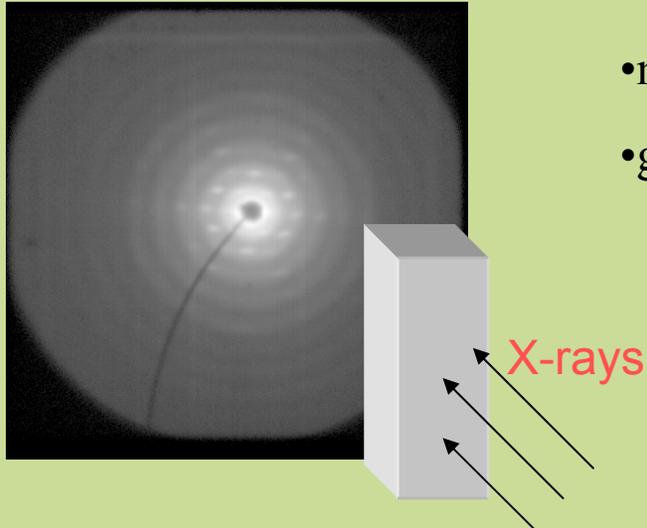
What is SAXS ?

(Small Angle X-ray Scattering)

- X-rays are scattered at electrons in atom shell
- momentum transfer q , scattering angle 2Θ
- geometry:

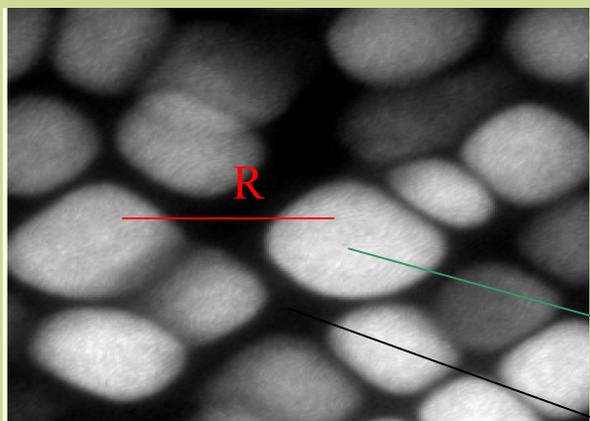


k : incident wavevector
 k' : scattered wavevector



➤ large q
 $(2\Theta > 1^\circ)$

- investigation of atomic distances (Angstrom)
- crystal: Bragg's equation: $2d \sin \Theta = n\lambda$



➤ small q
 $(2\Theta < 1^\circ)$

- distances R about 10nm - 1 μ m
- need a contrast in density
- intensity = Shape x form factor

precipitate
 amorphous matrix

interference due to assembly of particles

TEM of a Superalloy (Ni-Al solid solution matrix and precipitates (Al,..))

BW4: A dedicated beamline for:

- Small Angle X-Ray Scattering (SAXS), also USAXS ($d_{\max} > 1\mu\text{m}$) ($L_{\text{SD}} = 12\text{m}$)
- Grazing Incidence Small Angle X-Ray scattering (GISAXS)
- focussing with Be-lenses: minimum beam size of $30 \times 17 \mu\text{m}^2$
→ μGISAXS (small step-scanning along the sample)

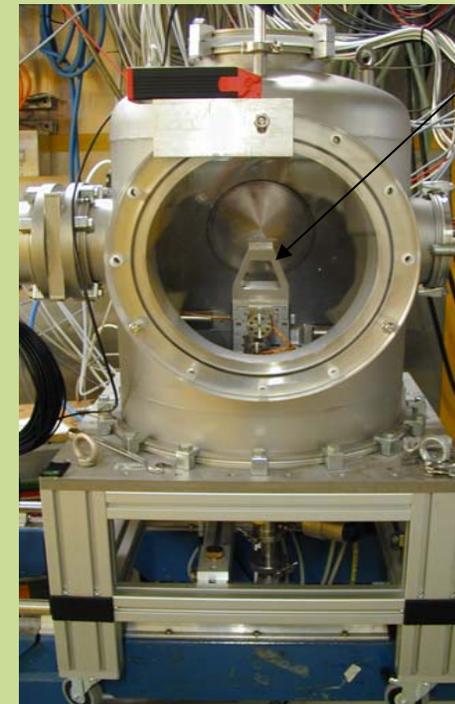


evacuated
sample
environment

Sample and
detector

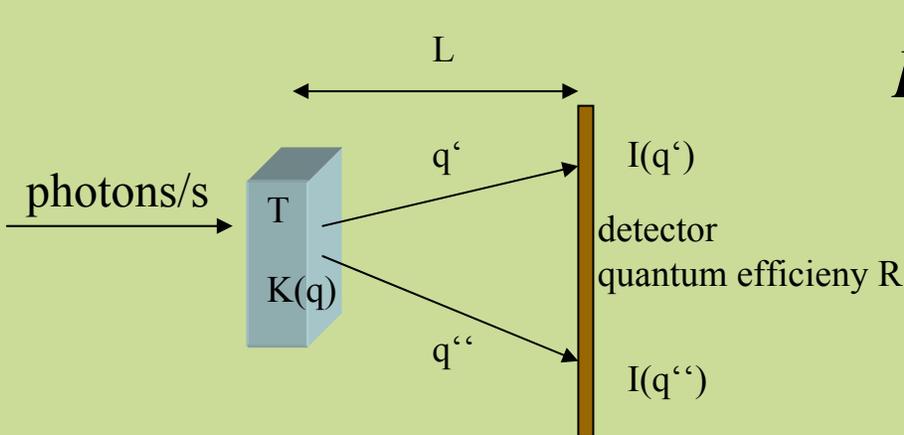
evacuated beam pipe
(around 10^{-6} mbar)

- sample to detector distances between 2m and 12m



Absolute intensity - what, why and how?

- ratio between scattered intensity $I(q)$ [photons / (s mm²)] to power P [photons/s] of incident beam
- by knowing the absolute intensity the electron density and relative atomic mass can be obtained
- the intensity at a certain scattering vector q' can be obtained by:



$$I(q') = P \cdot \frac{T}{L^2} \cdot R \cdot K(q')$$

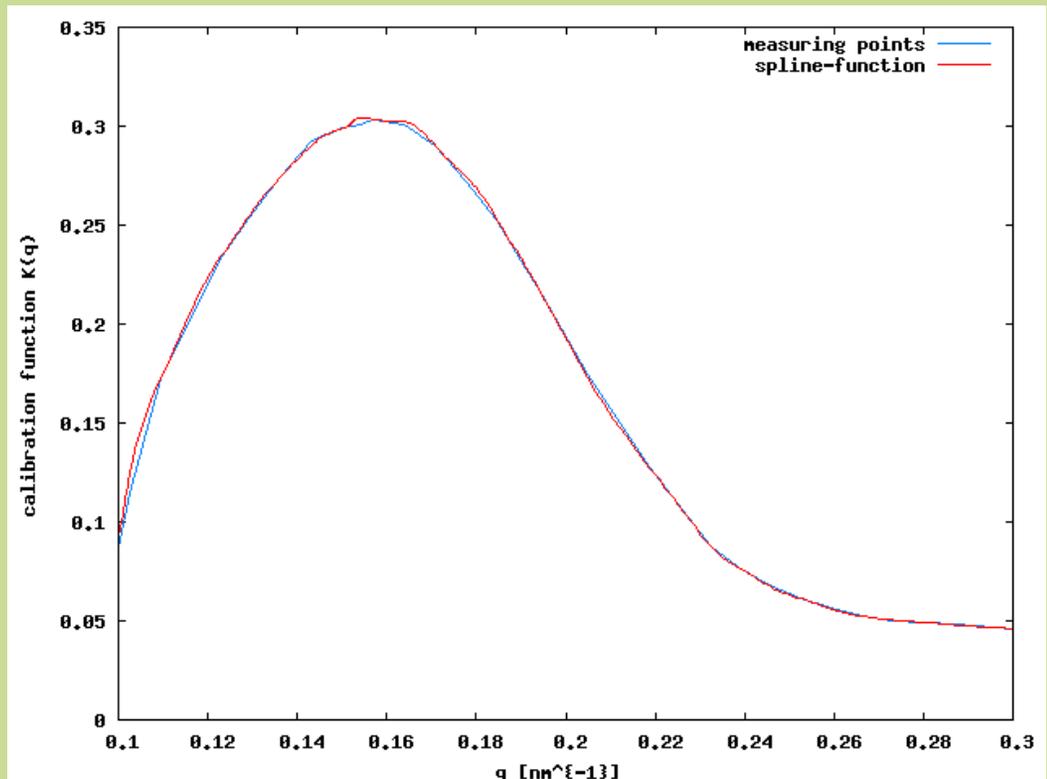
L: sample to detector distance
 T: transmission
 R: detector efficiency
 K(q): calibration function,
 contains the cross section

Calibration function

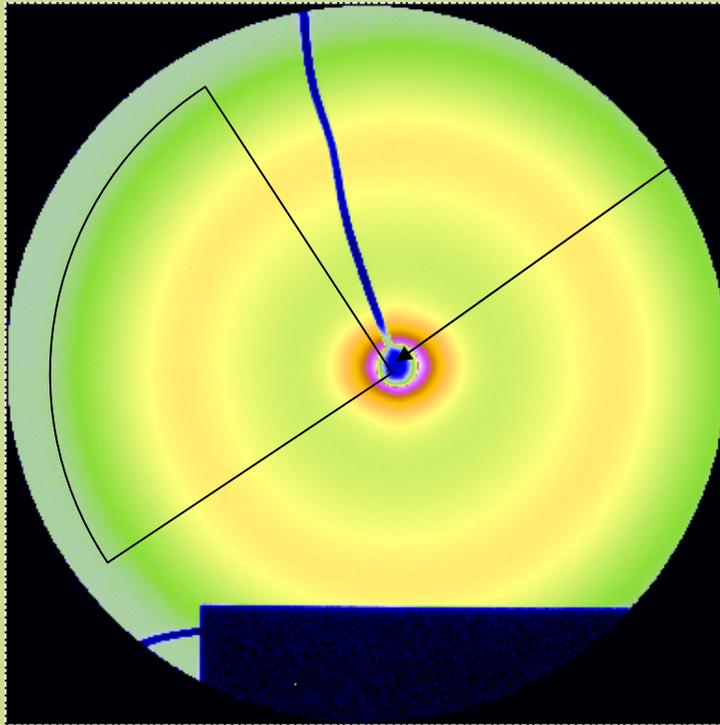
- calibration function $K(q)$ for a Lupolen sample was measured 10 years ago at BW4 using a Kratky camera
- beamline was upgraded, so a new calibration is needed

$$P = \frac{I(q')}{K(q')} \cdot \frac{L^2}{R \cdot T}$$

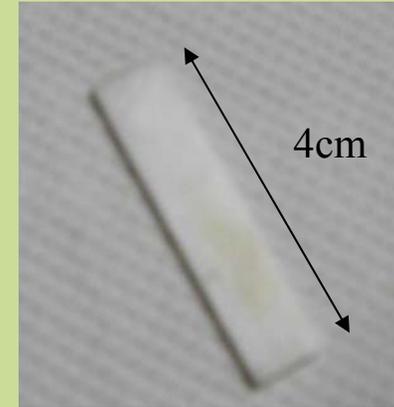
- obtaining P by measuring the scattering pattern of the Lupolen



Measurement of Lupolen

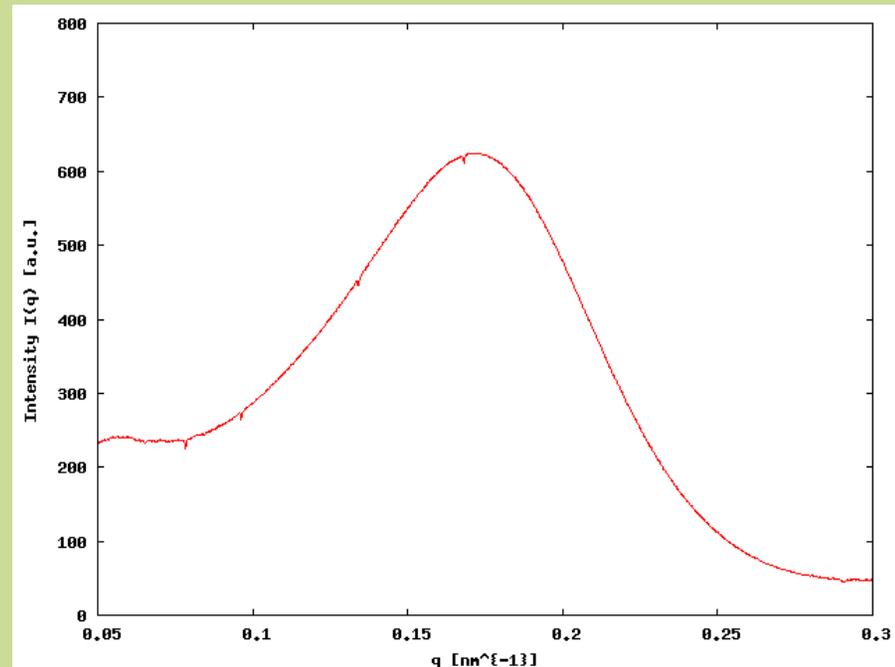


Beamstop



$$P = \frac{I(q')}{K(q')} \cdot \frac{L^2}{R \cdot T}$$

further parameters:
L=12855mm
R=0.8



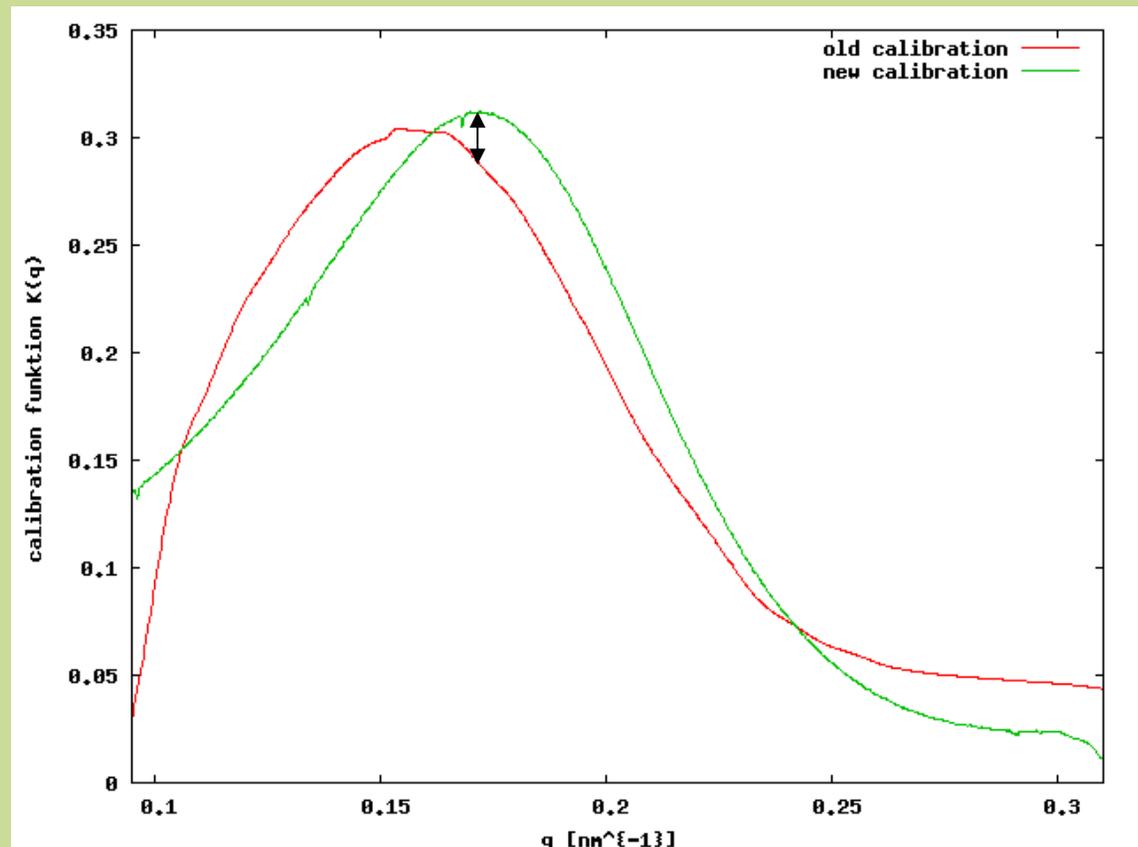
- transmission was obtained by an ionization chamber and beamstop diode

Results

$P = 6.67 \cdot 10^{11}$ photons/s at 100mA Doris current

(after systematic error correction, systematic error is around 7%)

- structure of Lupolen has changed
- but whole scattered intensity is conserved

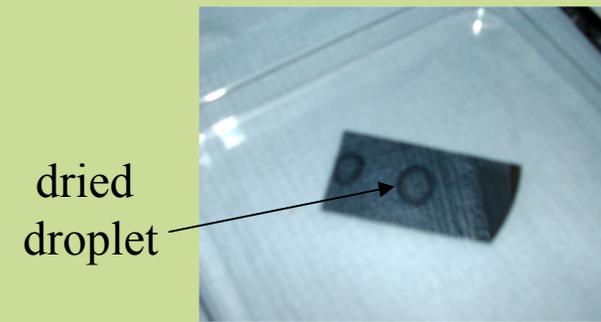
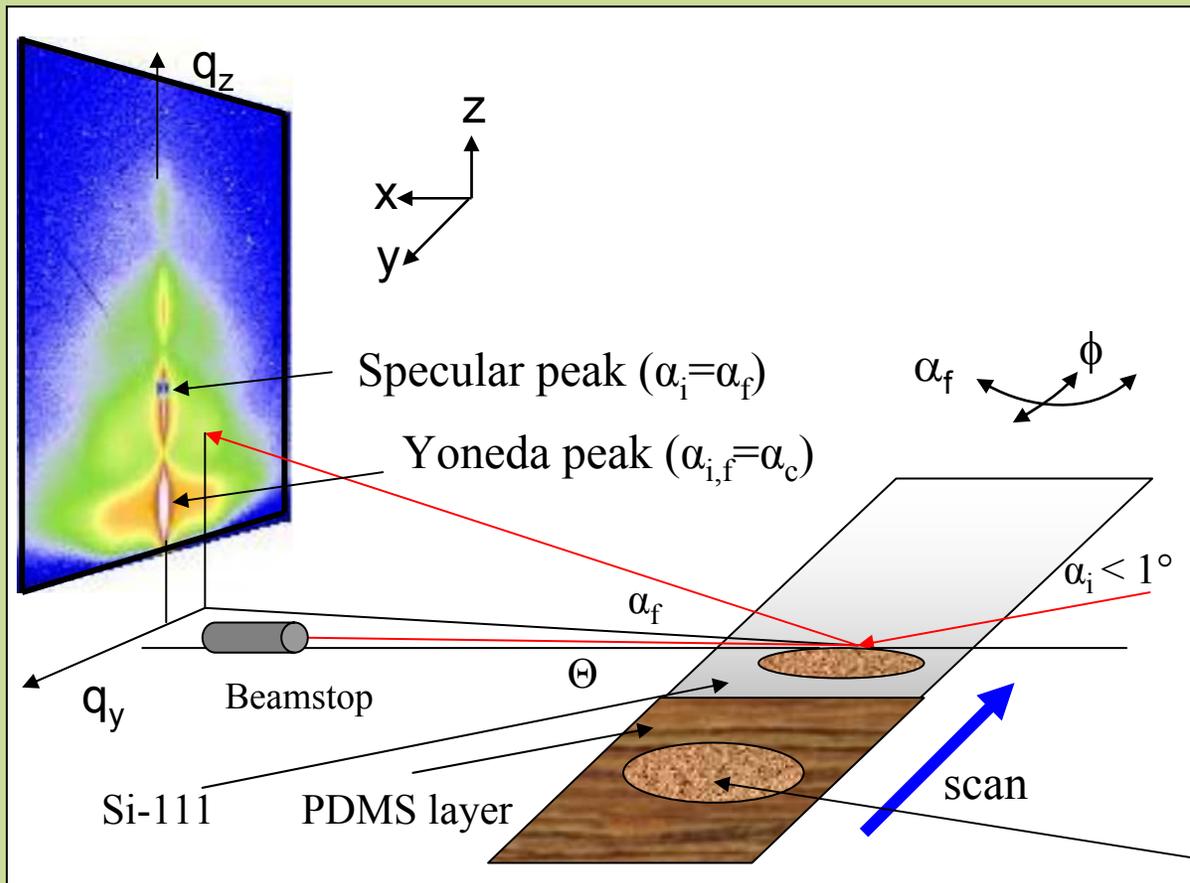


Grazing Incidence Small Angle X-ray Scattering

- surface sensitive method: penetration depth depends on the incident angle
- Yoneda peak: interference of incident and reflected beam at the critical angle
- Specular peak: Regular reflected beam

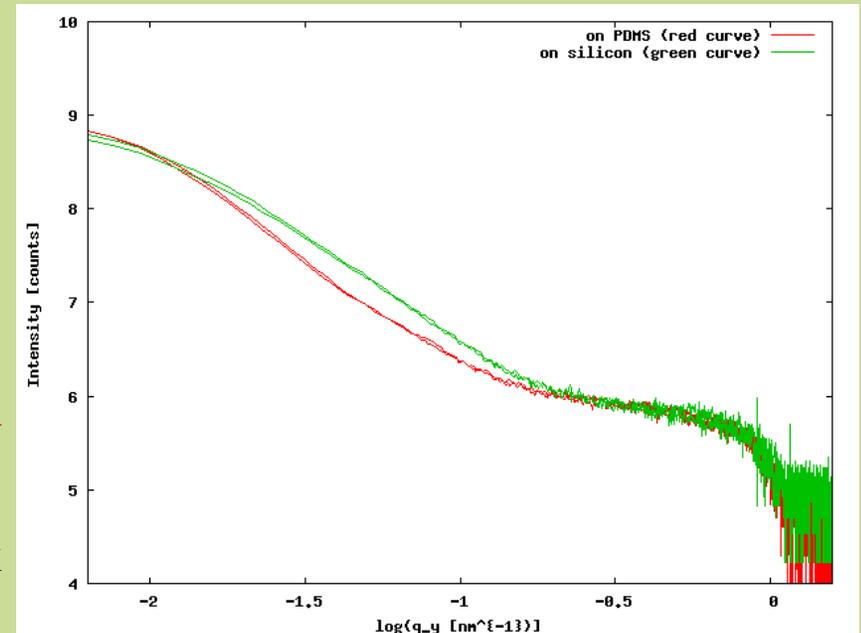
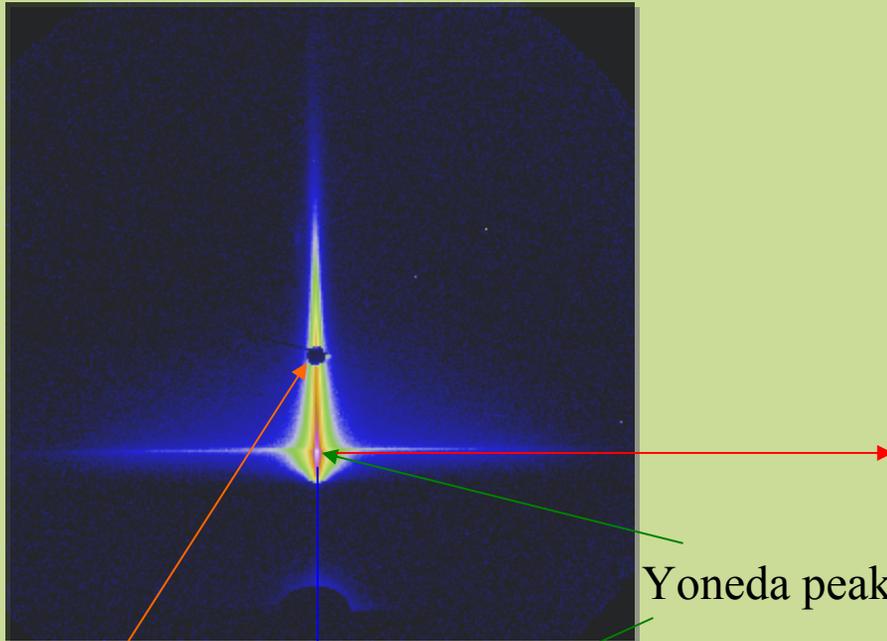
➤ Diffuse scattering:

- q_z -direction: mainly correlation perpendicular to surface (height of clusters, roughness, layer thickness)
- q_y -direction: In-plane structures (distances, radius)

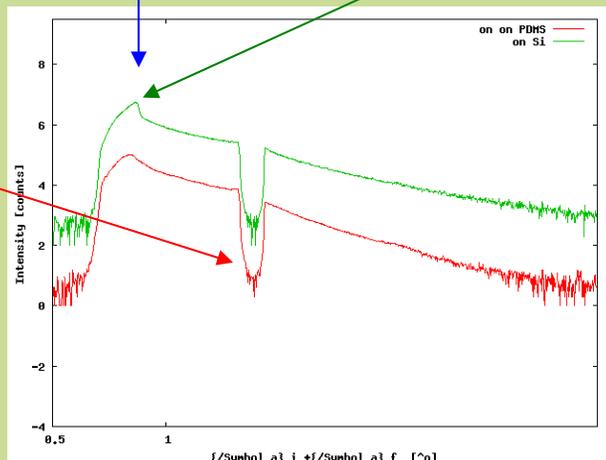


nanocluster in aqueous solution

μ GISAXS



Specular
peak



evaluation so far:

- small length scales \rightarrow no difference Si/PDMS
- larger length scales \rightarrow agglomeration of clusters on Si, distance about 120nm

\triangleright no agglomeration on PDMS

Thanks for your attention!!